




































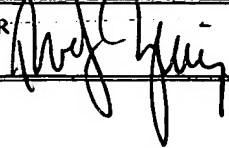
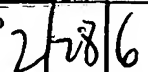


SHEET 1 OF 5

FORM PTO-1449		DOCKET NUMBER DSI 313CON		APPLICATION NUMBER 10/820,447			
INFORMATION DISCLOSURE CITATION IN AN APPLICATION		APPLICANTS Chung J. Lee et al.					
		FILING DATE April 7, 2004		GROUP ART UNIT 3746 1763			
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.	
10	3,268,599	08/23/1966	Chow	570	144		
	3,274,267	09/20/1966	Chow	570	129		
	3,280,202	10/18/1966	Gilch	570	144		
	3,288,728	11/29/1966	Gorham	528	86		
	3,332,891	07/25/1967	Chow et al.	528	391		
	3,342,754	09/19/1967	Gorham et al.	528	396		
	3,349,045	10/24/1967	Gilch	528	397		
	3,379,803	04/23/1968	Tittmann et al.	264	81		
	3,503,903	03/31/1970	Shaw et al.	528	396		
	V	3,509,075	04/28/1970	Niegish et al.	528	396	
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO	
10	EP 0 349 032 A2	01/03/1990	EPO			X	
	EP 0 523 479 A2	01/20/1993	EPO			X	
V	EP 0 856 503 A1	08/05/1998	EPO			X	
OTHER DOCUMENTS							
	Chow et al., <i>Poly (a,a,a',a'-tetrafluoro-p-xylylene)</i> , <i>Journal of Applied Polymer Science</i> , Vol. 13, No. 9, pp. 2325-2332, 1969.						
10	Chow et al., <i>The Synthesis of 1,1,2,2,9,9,10,10-octafluorou2, 2Paracyclophane</i> , <i>Journal of Organic Chemistry</i> , Vol. 35, No. 1, pp. 20-22, 1970.						
	Iwamoto et al., <i>Crystal Structure of Poly-p-xylylene. I. The a Form</i> , <i>Jour. Polymer. Sci. Polymer. Phys. Ed.</i> , Vol. 11, pp. 2403-2411, 1973.						
V	Iwamoto et al., <i>Crystallization During Polymerization of Poly-p-xylylene. III. Crystal Structure and Molecular Orientation as a Function of Temperature</i> , <i>Journal of Polymer Science Polymer. Phys. Ed.</i> , Vol. 13, pp. 1925-1938, 1975.						
EXAMINER- <i>Andrew Guerin</i>			DATE CONSIDERED <i>2/28/6</i>				

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FORM PTO-1449		DOCKET NUMBER DSI 313CON		APPLICATION NUMBER 10/820,447			
INFORMATION DISCLOSURE CITATION IN AN APPLICATION		APPLICANTS Chung J. Lee et al.					
		FILING DATE April 7, 2004		GROUP ART UNIT 3745 1763			
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.	
                 	3,626,032	12/07/1971	Norris	528	75		
	3,694,495	09/26/1972	Norris	562	496		
	3,940,530	02/24/1976	Loeb et al.	428	786		
	4,117,308	09/26/1978	Boggs	392	260		
	4,823,711	04/25/1989	Kroneberger et al.	110	236		
	5,268,202	12/07/1993	You et al.	427	285.6		
	5,320,518	06/14/1994	Stilger et al.	431	7		
	5,538,758	07/23/1996	Beach et al.	427	285.6		
	5,879,808	03/09/1999	Wary et al.	428	411.1		
	5,958,510	09/28/1999	Sivaramakrishnam	427	285.6		
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO	
          	GB 650 947	03/07/1951	Great Britain			X	
	GB 673 651	06/11/1952	Great Britain			X	
	WO 97/15699	05/01/1997	WIPO			X	
OTHER DOCUMENTS							
       	Lee, <i>Transport Polymerization of Gaseous Intermediates and Polymer Crystal Growth</i> , <u>J. Macromol. Sci. Rev. Macromol. Chem.</u> , C16(1), p. 79-127, 1977-78.						
	Sharma et al., <i>Optimizing Poly(chloro-p-Xylene) or Parylene C Synthesis</i> , <u>Journal of Applied Science</u> , Vol. 36, No. 7, pp. 1555-1565, Sept. 20, 1988.						
	Lee, <i>Polyimides, Polyquinolines and Polyquinoxalines: Tg-Structure Relationships</i> , <u>Journal of Macromolecular Science, Part C - Polymer Reviews</u> (formerly <u>Journal of Macromolecular Science, Part C - Reviews in Macromolecular Chemistry and Physics</u>) Vol. 29(4), pp. 431-560, 1989.						
	Lang, <i>Vapor Deposition of Very low k Polymer Films, Poly (Naphthalene), Poly (Fluorinated Naphthalene)</i> , <u>Materials Research Society Symposium Proceedings</u> , Vol. 381, pp. 45-50, April 17, 1995.						
EXAMINER			DATE CONSIDERED				
							

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FORM PTO-1449		DOCKET NUMBER DSI 313CON		APPLICATION NUMBER 10/820,447			
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		FILING DATE April 7, 2004		GROUP ART UNIT 3746 1763			
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.	
100	6,130,171	10/10/2000	Gomi, Hideki	438	781		
	6,140,456	10/31/2000	Foggiator	528	196		
	6,143,081	11/07/2000	Shinriki et al.	118	719		
	6,197,119	03/06/2001	Dozoretz et al.	118	715		
	6,265,320	07/24/2001	Shi et al.	438	725		
	6,265,495	07/24/2001	Hirata et al.	528	404		
	6,532,796	03/18/2003	Ikeda, Masayoshi	73	37		
	6,703,462	3/9/2004	Lee	526	212		
	6,797,343	9/28/2004	Lee	428	1.1		
	2003/0143341	7/31/2003	Lee	428	1.1		
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO	
100	WO 97/15951	05/01/1997	WIPO			X	
	WO 97/42356	11/13/1997	WIPO			X	
	WO 99/21705	05/06/1999	WIPO			X	
OTHER DOCUMENTS							
100	Wary et al., <i>Polymer Developed in the Interlayer Dielectric</i> , <u>Semi-Conductor International</u> , pp. 211-216, June 1996.						
	Wunderlick, <i>Crystal Nucleation, Growth, Annealing, Macromolecular Physics</i> , Vol. 1-2, pp. 178-217, 1996.						
	Ryan et al., <i>Effect of Deposition and Annealing on the Thermomechanical Properties of Parylene Films</i> , <u>Material Research Society Symposium Proceedings</u> , Vol. 476, pp. 225-230, 1997.						
	Greiner, <i>Poly(1,4-xylylene)s: Polymer Films by Chemical Vapour Deposition</i> , <u>Trends in Polymer Science</u> , Vol. 5, No. 1, pp. 12-16, 1997.						
EXAMINER			DATE CONSIDERED				
[Signature]			2/28/6				

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FORM PTO-1449		DOCKET NUMBER DSI 313CON		APPLICATION NUMBER 10/820,447		
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U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION YES NO
OTHER DOCUMENTS						
16	Mathur et al., <i>Vapor Deposition of Parylene-F Using Hydrogen as Carrier Gas</i> , <u>Journal of Materials Research</u> , Vol. 14, No. 1, pp. 246-250, 1999.					
	Morgen et al., <i>Morphological Transitions in Fluorinated and Non-Fluorinated Parylenes</i> , <u>Material Research Society Symposium Proceedings</u> , Vol. 565, pp.297-302, 1999.					
	Peng and McGivern, <i>Quantum Yields and Energy Partitioning in the UV Photodissociation of Halon 2402</i> , <u>Journal of Chemical Physics</u> , Vol. 113, No. 17, pp. 7149-7157, 2000.					
	Brun, <i>100nm: The Undiscovered Country</i> , <u>Semiconductor International</u> , p. 79, February 2000.					
	Rashed, <i>Properties and Characteristics of Silicon Carbide</i> , website publication (www.poco.com), POCO Graphite Inc. 2002.					
EXAMINER	DATE CONSIDERED			2/28/6		